Tandem synthesis of polypropionate chains-highly stereoselective synthesis of the ansa chain of streptovaricin U and protostreptovaricins based on stereospecific methylation of γ , δ -epoxy acrylates by trimethylaluminium

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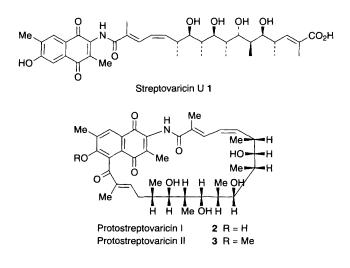
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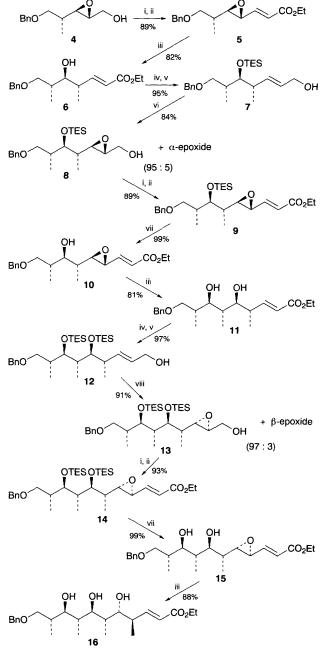
The highly stereoselective synthesis of the ansa chain segment 23 of streptovaricin U and protostreptovaricins (I and II) is achieved by stereospecific methylation of γ , δ -epoxy acrylates with trimethylaluminium.

The streptovaricin family including protostreptovaricins and damavaricins are representative ansamycin antibiotics as well as rifamycins and are a clinically important class of antibiotics.¹ All the streptovaricin antibiotics consist of a unique naphthoquinone core and a polypropionate ansa chain composed of nine contiguous chiral centres.¹ Among them streptovaricin U 1 is a novel open-chain ansamycin and has inhibitory activity against RAUSCHER leukemia virus RNA-dependent DNA polymerase.² Unique structures and important biological activities of the streptovaricins have elicited considerable attention from synthetic chemists.³

Recently we developed a novel stereospecific methylation of γ , δ -epoxy acrylates with trimethylaluminium in the presence of water,⁴ which provides a useful means for the synthesis of natural products.⁵ We report here a tandem methodology for the synthesis of polypropionate chains based on the above methylation reaction involving the first and stereospecific synthesis of the ansa chain of streptovaricin U 1 and protostreptovaricins I 2 and II 3 having nine chiral centres.

The starting material 4, a chiral epoxy alcohol easily available from (S)-3-benzyloxy-2-methylpropanol,⁶ was subjected to the Swern oxidation followed by the Horner–Emmons reaction with triethyl phosphonoacetate to give the γ , δ -epoxy acrylate 5† in 89% yield, Scheme 1. Upon treatment of 5 with excess trimethylaluminium in the presence of water in 1,2-dichloroethane at -30 °C, methylation reaction took place at the γ -position with complete regio- and stereo-selectivity to afford the alcohol **6** as the sole product in 82% yield. No isomeric products were formed. After protection of the hydroxy group of



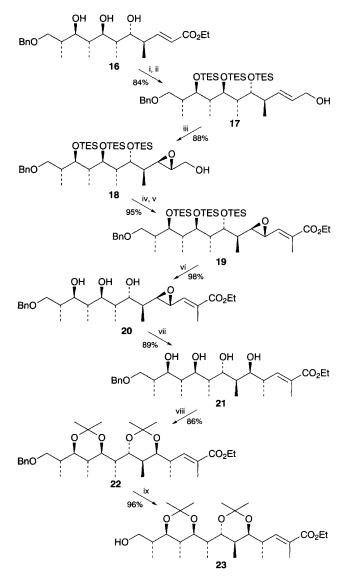


Scheme 1 Reagents and conditions: i, (COCl)₂, Me₂SO, CH₂Cl₂, -70 °C, then Et₃N; ii, (EtO)₂POCH₂CO₂Et, NaH, THF, 0 °C, then aldehyde at -78 °C; iii, Me₃Al (10 equiv.), H₂O (6 equiv.), ClCH₂CH₂Cl₁, -30 °C; iv, TESCl, imidazole, DMAP, CH₂Cl₂; v, DIBAL-H, toluene, -78 °C; vi, Ti(OPrⁱ)₄, D-(-)-DET, Me₃COOH, CH₂Cl₂, -23 °C; vii, Bu₄NF, THF, 0 °C; viii, MCPBA, CH₂Cl₂, -10 °C

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6 with chlorotriethylsilane (TESCl), reduction of the ethyl ester with diisobutylaluminium hydride (DIBAL-H) gave the allylic alcohol 7 in 95% yield from the 2 steps. The Katsuki-Sharpless asymmetric epoxidation⁷ of the resulting allylic alcohol with D-(-)-diethyl tartrate furnished a 95:5 mixture of the desired β epoxy alcohol 8 and its α -isomer in 84% combined yield. Since these epoxides could not be separated by silica gel chromatography, the mixture was directly submitted to Swern oxidation followed by Horner-Emmons reaction with triethyl phosphonoacetate to give the γ , δ -epoxy unsaturated ester 9 in 89% yield.[‡] After removal of the triethylsilyl group of 9 with tetrabutylammonium fluoride in THF (99%), the corresponding epoxy alcohol 10 was subjected again to the crucial methylation reaction.§ Thus the treatment of 10 with excess trimethylaluminium in the presence of water at -30 °C produced the dihydroxy ester 11 having five contiguous chiral centres in 81% isolated yield. In this case too, the methylation reaction occurred in very high diastereoselectivity (>99%).

The dihydroxy ester 11 was transformed into the allylic alcohol 12 by the same sequence of reactions for 6 to 7: protection of the hydroxy groups with TESCl followed by reduction with DIBAL-H (97% for the 2 steps). Subsequent



Scheme 2 Reagents and conditions: i, TESCl, Imidazole, DMAP, CH_2Cl_2 ; ii, DIBAL-H, toluene, -78 °C; iii, MCPBA, CH_2Cl_2 , -10 °C; iv, $(COCl)_2$, Me_2SO , CH_2Cl_2 , -70 °C, then Et_3N ; v, $Ph_3P=C(Me)CO_2Et$, THF; vi, Bu_4NF , THF, 0 °C; vii, Me_3Al (10 equiv.), H_2O (6 equiv.), CH_2Cl_2 , -45 °C; viii, $Me_2C(OMe)_2$, PPTS, CH_2Cl_2 ; ix, H_2 , Pd–BaSO₄, EtOH

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treatment of 12 with MCPBA in dichloromethane gave a 97:3 mixture of the desired α -epoxy alcohol 13 and its β -isomer in 91% yield. The epoxide mixture was directly submitted to the Swern oxidation followed by the Horner–Emmons reaction with triethyl phosphonoacetate to afford the γ , δ -epoxy unsaturated ester 14 in 93% yield.‡ After removal of the triethylsilyl group of 14 with tetrabutylammonium fluoride (99%), the resulting epoxy diol 15 was subjected to a third methylation with trimethylaluminium. The reaction took place with complete diastereoselectivity to yield the trihydroxy ester 16 as the sole product in 88% yield. In this way, the segment 16 having seven chiral centres was efficiently and straightforwardly synthesized by repeating three times the key methylation reaction with trimethylaluminium.

Introduction of the remaining two chiral centres was accomplished as follows, Scheme 2. The trihydroxy ester 16 was converted to the allylic alcohol 17 by a two-step reaction sequence: (1) protection of the hydroxy groups with TESCI and (2) reduction with DIBAL-H (84% yield for the 2 steps). In turn the allylic alcohol 17 was oxidized with MCPBA to give a single β -epoxy alcohol **18** in 88% yield, which was transformed into the corresponding γ, δ -epoxy unsaturated ester 19 by Swern oxidation and subsequent Wittig reaction with (carbethoxyethylidene)triphenylphosphorane in 95% yield. After removal of the triethylsilyl groups of 19 with tetrabutylammonium fluoride (98%), the resulting epoxy triol 20 was subjected to a fourth methylation with trimethylaluminium. The key methylation reaction was carried out at -45 °C in dichloromethane to furnish the desired product 21 in 89% isolated yield along with other diastereoisomers. Compound 21 was then transformed intthe bis-acetal 22. Finally, the benzyl protecting group of 22 was removed by hydrogenolysis over Lindlar catalyst to cleanly provide the target molecule 23, $[\alpha]_D^{22}$ + 6.8 (c 0.56, CHCl₃), having nine chiral centres in 96% yield.

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Footnotes

[†] All new compounds had satisfactory spectra (¹H and ¹³C NMR, IR) and elemental analyses.

[‡] At this stage, the major product was cleanly separated from the minor one by silica gel column chromatography.

§ Reaction of the triethylsilyl compound itself with trimethylaluminium was very sluggish and resulted in a complex mixture.

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